

Notice of References Cited	Application/Control No. 10/690,573	Applicant(s)/Patent Under Reexamination SONG ET AL.	
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	B	US-6,914,641	07-2005	Choo et al.	349/38
	C	US-5,838,314	11-1998	Neel et al.	725/8
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
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	M	US-			

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